	Hit s	Search Text	DBs
47	2	((substrate or wafer or device or workpiece) same (support\$3 or stage or hold\$3 or platen) same (photosensitive or photoresist or resist)) and (pattern\$4 same (mask or reticle or photomask)) and (plasma or e\$3beam or (electron near4 beam) or beam or RF or (electro\$3magnetic near6 field) or (plasma near5 source) or EUV or DUV or laser or (projection near9 system)) and (gas\$3 same (plasma or ion\$3beam or beam or laser or ion\$4assist\$5 or ion\$4beam) same ((perchlorinated or perbrominated or periodinated or chloro or bromo or iodo or chlorine or iodine or bromine or halogen or (halogenated near9 alkane) or perhalogenat\$3) near29 (alkane or methane or ethane or propane or butane or pentane)))	USPAT; EPO; JPO; DERWENT;

	Hit s	Search Text	DBs
48	26	or DUV or laser or (projection near9 system)) and (gas\$3 same (plasma or ion\$3beam or beam or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
49	30	neary system) or (collector near12 optics) or (light near12 source)) and ((gas\$3 or etchant)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit	Search Text	DBs
50	41	near9 system) or (collector near12 optics) or (light near12 source)) same (gas\$3 or etchant or plasma or ion\$3beam or beam or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
51	15	S50 NOT S48	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
52	2	((projection near9 system) or (collector near12 optics) or (light near12 source)) same	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
53	1	((substrate or wafer or device or workpiece) same (photosensitive or photoresist or resist) same (expos\$4 or irradiat\$4 or illuminat\$4)) and ((plasma or e\$3beam or (electron near4 beam) or beam or RF or (electro\$3magnetic near6 field) or (plasma near5 source) or EUV or DUV or laser) same ((projection near9 system) or (collector near12 optics) or (light near12 source)) same (gas\$3 or etchant or plasma or ion\$3beam or beam or laser or ion\$4assist\$5 or ion\$4beam or ions) same ((perchlorinated or perbrominated or perbrominated or perbrominated or bromine or halogen or (halogenated near9 alkane) or perhalogenat\$3) near29 (alkane or methane or ethane or propane or butane or pentane)))	US-PGPUB

	Hit s	Search Text	DBs
54	6	perbrominated or periodinated or carbontetrachloride or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
55	6	ions) same ((perchlorinated or perbrominated or carbontetrachloride or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
56	15	carbontetrachloride or tetrachloromethane or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
57	104	tetrabromomethane or carbontetrabromide or carbontetraiodide or trichloromethane or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

		((gas\$3 or etchant or plasma or	
		ion\$3beam or beam or laser or	
		ion\$4assist\$5 or ion\$4beam or	
		ions or radiation) same	
		((fluorine or perchlorinated or	
		perbrominated or periodinated or	
		carbontetrachloride or	
		tetrachloromethane or	
		tetrabromomethane or	US-PGPUB;
		carbontetrabromide or	USPAT; EPO;
58	122	carbontetraiodide or	JPO;
		trichloromethane or	DERWENT;
		tribromomethane or triiodomethane	IBM_TDB
		or chloro or bromo or iodo or	
		chlorine or iodine or bromine or	
		chlorofluorocarbon or flons or	
		halogen or (halogenated near9	
		alkane) or perhalogenat\$3) near29	
		(alkane or methane or ethane or	
		propane or butane or pentane))	
		same (cleaning or contamination))	

	Hit s	Search Text	DBs
59	18	S59 NOT S58	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
60	104		US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
61	103	carbontetrabromide or carbontetraiodide or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
62	86	tetrabromomethane or carbontetrabromide or carbontetraiodide or trichloromethane or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
63	154	carbontetrabromide or carbontetraiodide or trichloromethane or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
6 4	86	tetrabromomethane or carbontetrabromide or carbontetraiodide or trichloromethane or triiodomethane or chloro or bromo or iodo or chlorine or iodine or bromine or chlorofluorocarbon or flons) near29 (alkane or methane or ethane or propane or butane or pentane)) same (cleaning or contamination))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
65	104	S64 NOT S65	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
66		chlor\$5hydrocarbons or chloromethane or chlorofluorocarbon) near29	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
67		chloromethane trichloromethane or chlorofluorocarbon) near29 (alkane or methane or ethane or	JPO;